

L Number	Hits	Search Text	DB	Time stamp
28	10538	((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:20
29	1	(((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:21
30	0	(((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and organic	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:21
31	75544	crysattline and metal and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:21
32	461	(crysattline and metal and solvent) and ("anti reflective" "anti reflection")	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:22
33	460	((crysattline and metal and solvent) and ("anti reflective" "anti reflection")) not (((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and solvent)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:22
34	226	((((crysattline and metal and solvent) and ("anti reflective" "anti reflection")) not (((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and solvent)) and high and refractive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:22
35	226	((((crysattline and metal and solvent) and ("anti reflective" "anti reflection")) not (((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and solvent)) and high and refractive) and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:24
36	48	(((((crysattline and metal and solvent) and ("anti reflective" "anti reflection")) not (((428/429,432,441,446,448,412).CCLS.) ((359/580,582,586).CCLS.)) and metal and crysattline and solvent)) and high and refractive) and solvent) and curable "crysattline metal" and high adj refractive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:26
37	0		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:26
38	48	"crysattline metal" and high adj refractive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:51
39	5	"crysattline metal" and colloid and organosilane	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:15
40	1		USPAT	2003/12/09 14:52
41	220	"crysattline metal" and amide and solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:16
42	93	("crysattline metal" and amide and solvent) and dimethylformamide	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:16
43	89	(("crysattline metal" and amide and solvent) and dimethylformamide) not (("crysattline metal" and colloid and organosilane)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:25

44	1	((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:16
45	88	((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:25
46	20	((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:41
47	200	((("crystalline metal" and amide and solvent) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:41
48	73	((("crystalline metal" and amide and solvent) and dimethylformamide) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:43
49	147	((("crystalline metal" and amide and solvent) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:43
50	127	((("crystalline metal" and amide and solvent) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive))) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) not (((("crystalline metal" and amide and solvent) and dimethylformamide) not ("crystalline metal" and colloid and organosilane)) and antireflection)) and refractive))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 15:43

-	3	he-liu.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 06:40
-	0	park-sung-soon.in	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 06:40
-	4	park-sung-soon.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:20
-	11	zheng-haixing.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:22
-	1	tang-grace.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:23
-	1	vance-aylin.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:23
-	37	chemat.as.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:27
-	130	(tetralkoxysilane trialkoxysilane dialkoxysilane) and fluoroalkyl	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:28
-	130	((tetralkoxysilane trialkoxysilane dialkoxysilane) and fluoroalkyl) not chemat.as.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 07:28
-	15	((tetralkoxysilane trialkoxysilane dialkoxysilane) and fluoroalkyl) not chemat.as.) and (refraction refractive) and index	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:20
-	26408	(acrylate acrylic) and functionality	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:20
-	2145	((acrylate acrylic) and functionality) and refractive	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:20
-	2077	((acrylate acrylic) and functionality) and refractive) and index	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:21
-	1440	((acrylate acrylic) and functionality) and refractive) and index) and layer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:21
-	717	((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:22
-	307	((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:22
-	585	((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and ultraviolet	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:23

-	0	(((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable) and "electron beam") and crystalline adj meta	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:23
-	4	(((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:28
-	303	(((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable) and "electron beam") not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:28
-	259	((((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)) and thickness	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:49
-	62	((((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)) and thickness and multilayer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 08:56
-	197	((((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)) and thickness not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)) and thickness not (((((acrylate acrylic) and functionality) and refractive) and index) and layer) and (ultraviolet radiation "electron beam") and (cured curable)) and "electron beam") and crystalline adj metal)) and thickness and multilayer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 09:35
-	174171	"antireflective" "AR"	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 09:36
-	25438	("antireflective" "AR") and coating and layer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 09:37

-	3680	((("antireflective" "AR") and coating and layer) and refractive and index	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 09:37
-	20	((("antireflective" "AR") and coating and layer) and refractive and index) and crystalline adj metal	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:45
-	8823	(428/429, 432, 441, 446, 448, 412).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:51
-	1056	(359/580, 582, 586).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:51
-	9753	((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/09 14:15
-	2955	((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)) and (radiation ultraviolet "electron beam")	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:54
-	919	((((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)) and (radiation ultraviolet "electron beam")) and (refractive refraction) and index	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:55
-	893	(((((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)) and (radiation ultraviolet "electron beam")) and (refractive refraction) and index) and thickness	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:55
-	468	(((((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)) and (radiation ultraviolet "electron beam")) and (refractive refraction) and index) and thickness) and (polymer monomer)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 11:55
-	126	((((((428/429, 432, 441, 446, 448, 412).CCLS.) ((359/580, 582, 586).CCLS.)) and (radiation ultraviolet "electron beam")) and (refractive refraction) and index) and thickness) and (polymer monomer)) and ("AR" antireflective "anti reflective") ("6544587").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 16:17
-	2		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/05/27 16:17